Improved application beam line and recent experiments on the NIJI-IV DUV/VUV FEL

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Compact NIJI-IV FEL system Improvement of optical cavity Cavity-mirror degradation NIJI-IV DUV FEL for PEEM application Summary



NIJI-IV FEL

3.6 m Optical Klystron Vacuum Mirror Manipulator **RF** Cavity **ETLOK-III** $(1 - 10 \ \mu m)$ FE **Electron Injection** Septum Magr Kicker Magnet 6.3 m Optical Klystron³ **ETLOK-II** UV/VUV FEL (198 - 595 nm)

	ETLOK-II	ETLOK-III
Total length [m]	6.288	3.55
Magnetic period		
Undulator section [mm]	72	200
Dispersive section[mm]	216	720
Number of period $N_{\rm u}$	42 × 2	7 × 2
Deflection factor K	<2.29	<10.04
Wavelength [µm]	0.198-0.595	(0.4-10)

Lasing in the NIJI-IV FEL



Line width: 0.07nm

DUV/VUV Beam line for FEL-PEEM(Photoelectron emission microscopy)



An FEL at a wavelength of 202nm emitted from a 6.3-m optical klystron ETLOK-II was transported to the experimental room through air and was reflected by a flat aluminium mirror and focused onto the sample surface.

Optical cavity system for DUV/VUV FEL

Robust optical cavity sytem



Old system



Slender structure

The mirror manipulators were composed of five-axis stages with gimbal mounts containing a highvacuum mirror chambers each of which has interchangeable two in-vacuum mirrors to extend FEL tuning range.

heavy granite stone(2 ton) Resolution: $\Delta z = 0.1 \mu m$, $\Delta \theta = 0.8 \mu rad$

Degradation of dielectric mirror in the visible and UV regions



O_2 plasma treatment in the visible and UV regions

RF SAMPLE





Fig. 2. Restoration of a degraded IBS mirror with plasma treatment and thermal annealing. Exposure dose to the sample was 15.9 mA h.



Fig. 5. Typical x-ray photoelectron spectra before and after plasma treatment.

Reduction of carbon contamination after plasma treatment was confirmed by XPS analysis.

We already demonstrated to TiO_2/SiO_2 , Ta_2O_5/SiO_2 , HfO_2/SiO_2 .

K.Yamada Appl. Opt. 34 (1995)

Mirror Loss Measurement — Cavity ring-down method



Mirror degradation around 200nm



The mirror bandwidth was narrowed. \implies O₂ plasma treatment

RF-induced O₂ plasma treatment



To remove surface carbon contamination, the surface was treated with O_2 plasma.







O₂ gas : flow rate of 100ml/min 60Pa RF: 13.56MHz, 300W

The treatment time of at least 20sec is enough to restore the degraded mirror.

After O₂ plasma treatment



The narrowing of the mirror bandwidth disappeared and the shape of mirror loss curve was repaired, while the absolute value was still larger.

volume degradation through defect formation inside the dielectric layers.

thermal annealing treatment

After thermal annealing treatment



Degradation was almost restored.

To examine the degradation mechanism due to inner defects, we performed positron lifetime experiments.

Depth-selective PALS(Positron Annihilation Lifetime Spectroscopy) system



Result of Positron experiment



In the UV and visible regions, the defect was completely repaired with $230-250^{\circ}$ C annealing In the DUV/VUV, annealing should be more higher temperature to repair completely.

NIJI-IV FEL-PEEM (photoelectron emission microscopy) System



NIJI-IV DUVFEL was applied to surface observation, in combination with a PEEM system (STAIB Instrumente, type 350). This PEEM system has three sets of electrostatic electron lenses and a micro channel plate (MCP) equipped with a fluorescent screen. By viewing the focused images on the fluorescent screen with a CCD camera, transient phenomena, such as chemical reactions on transition-metal surfaces, can be monitored with video-rate time resolution. Since the spatial resolution of this system is 80 nm and our FEL intensity is large enough to extract sufficient amount of photoelectrons to recognize the surface contrasts within 33.3 msec, we can examine real-time physical and chemical information on transition-metal surfaces in a sub-micron scale.



Catalytic CO oxidation $(2CO + O_2 \ 2CO_2)$ on a Pd(111) surface

In case of Pt(110)

 Pt(110)
 5.5eV

 Pt(110) \oplus CO
 5.8eV

 Pt(110) \oplus O
 6.5eV

Workfunction 5.5eV 5.8eV 6.5eV



pure Pd(111) surface



bright surface

 $Pd(111) \oplus CO$



Exposed to CO gas dark surface Produced CO₂ gas desorbs immediately.



Exposed to O_2 gas

K.Yamada: FEL Conf. 2004

Expansion of CO domain on a Pd(111) surface



Exposure CO (5 × 10⁻⁶ Pa) O₂ (4 × 10⁻⁵ Pa) T = 360K

It is supposed that the oxygen play a role in preventing a speed of CO expansion.

Observation of Cs₂Te Photocathode



1 x 10 /incident photon) Cs₂Te Te ABSOLUTE QUANTUM YIELD (electroni O. OUANTUM ← 200nm 🗠 9 10 11 12 10 PHOTON **NIJI-IV FEL** talk on Wednesday by Kuroda

354nm

Observation is now proceeding



Summary

- Stable optical cavity system was installed for DUV/VUV and IR FEL.
- Degradation in Al₂O₃/SiO₂ mirror was studied around 200nm. The degraded mirror was successfully restored by treatment of O₂ plasma and thermal annealing.
- As for FEL application study, a real-time imaging of chemical reaction was performed with PEEM and Cs₂Te photocathode observation is now proceeding.

